

From Target to Substrate – About the Generation of Energetic Ions in HiPIMS Discharges

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Acknowledgements



Challenge HiPIMS



Controlling energy input during deposition in HiPIMS





HPPMS results in smaller grains and smoother films compared to dcMS

N.Bagcivan,K.Bobzin,G.Grundmeier,C.Kunze,R.H.Brugnara, Thin Solid Films (2013) http://dx.doi.org/10.1016/j.tsf.2013.06.036

HPPMS-Plasmas Azimuthal Movement of Plasma Spokes in ExB direction



Ehiasarian AP, Hecimovic A, de los Arcos T, New R, Schulz-von der Gathen V, Böke M, et al. Applied Physics Letters 100, 114101 (2012) Hecimovic A, de los Arcos T, Schulz-von der Gathen V, Böke M, Winter J. Plasma Sources Science and Techonology 21, 035017 (2012) Winter J, Hecimovic A, de los Arcos T, Böke M, Schulz-von der Gathen V. Journal of Physics D: Applied Physics. 46, 084007 (2013)

HPPMS – Spokes Top View



Many Publications on Spokes by Anders, Ehiasarian, Lundin, Brenning, Gudmundson,...

Ehiasarian AP, Hecimovic A, de los Arcos T, New R, Schulz-von der Gathen V, Böke M, et al. Applied Physics Letters 100, 114101 (2012) Hecimovic A, de los Arcos T, Schulz-von der Gathen V, Böke M, Winter J. Plasma Sources Science and Techonology 21, 035017 (2012) Winter J, Hecimovic A, de los Arcos T, Böke M, Schulz-von der Gathen V. Journal of Physics D: Applied Physics. 46, 084007 (2013)

HPPMS – Spokes Side View



Plasma Flares in HiPIMS Ar (630-680 V, 500 A)

P. Ni, C. Hornschuch, M. Panjan, A. Anders, Appl. Phys. Lett. 101, 224102 (2012);

Following the Spoke Dynamic in Single Pulses by a Probe Array



RUB

Following the mode number with the probe array



Following Spoke Mode Transitions in a single Plasma Pulse



A. Hecimovic, C. Maszl, V. Schulz-vpn der Gathen, M. Böke, A. von Keudell, Plasma Sources Sci. Technol (2015).

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Following Spoke Mode Transitions in a single Plasma Pulse



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Velocity of the Spokes



A Hecimovic, C Maszl, V Schulz-von der Gathen, M Böke and A von Keudell Plasma Sources Science and Technology 06/2016; 25(3):035001





IEDFs during HiPIMS of Ti⁺ ions

0.98kW/cm²



2964 W/cm2

thermalized Ti⁺ dominant energetic Ti only 0.1% of ion flux Ti⁺ from sputter wind dominant energetic Ti 10% of ion flux

Distinct energetic peaks ?

W. Breilmann, C. Maszl, A. von Keudell Plasma Sources Sci. and Technol. (2017) DOI: https://doi.org/10.1088/1361-6595/aa56e5

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From pulsed dc-MS to HPPMS plasmas

- Group of higher energy ions (HE) appears simultaneously with low energy ions (LE)
- LE ions increase in energy at later stages of the HiPIMS pulse
- HE ions remain at constant energy, only the distribution broadens



time (µs)

Most easiest explanation Two groups of ions (HE and LE) are created at two distinct positions of electrical potential

C. Maszl, W. Breilmann, J. Benedikt, A. von Keudell, J. Phys. D 47, 224002 (2014)

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0.5 Pa, Ar, @3 kW/cm2

Plasma potential model to explain distinct HE and LE peaks



Rotation of Spokes

The dominating E-field surrounding the spoke determines its rotation* (following PoP Frias, Kaganovich, Smolyakov, Raitses)



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Drift waves to explain direction of motion and velocities*

(following PoP Frias, Kaganovich, Smolyakov, Raitses)



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RUHR-UNIVERSITÄT BOCHUM

Measurement of the distributed current in the target

- Flat probe -36 V bias, 1 mm from the anode cover edge
- 12 pins in target (4.9 mm pin diameter), same potential

Al target, **4 pins**,



flat probe

μ

.0 mm

Measurement of the distributed current in the target

Difficulty is to avoid Arcing and hollow cathode effects





Measurement of the distributed current in the target



Measurement of the distributed current in the target

$I_d \simeq 50 \text{ A}, \text{ m} = 3, \text{ Al target}$



Current on pin I_p and discharge current I_d exhibit similar trend

I_p is never zero* Modulation ~ 30% (*Qualitatively similar to Poolcharuansin JAP **117**, 163304 (2015),)

Current density **j** over pin is about 6 A/cm²

This yields plasma density at sheath edge of ~ 10²⁰ m⁻³ from Bohm criterion

Diagnostic Challenge HiPIMS – Measurement inside a spoke



Diagnostic Challenge HiPIMS – Measurement inside a spoke



Diagnostic Challenge HiPIMS – Measurement of a Dynamic plasma

Triggering at 2 times necessary

- Beginning of the pulse
- Presence of a spoke in the diagnostic window





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Diagnostic Challenge HiPIMS – Measurement of a Dynamic plasma

Triggering at 2 times necessary

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Spoke Phenomenon – the Unknowns

Experimental

- Electrical potential no data inside the spoke available
- Electron density sparse data by Stark broadening or Interferometry
- Modulation of the current ~ 30% + x Plasma emission is not equivalent to plasma current density

Plasma Modeling

- Fluid Model seems to be applicable, good agreement with drift waves, but saturation values? Long mean free paths?
- Models need to invoke dynamic variation of gas rarefaction
- IRM type Global Models for an inherent 3D phenomenon
- PIC models not yet capable to cover 3D dynamic at high plasma density

Energy of the lons in HiPIMS Plasmas

Properties of Spokes

- 1) Electrical Structure in the plasma determines direction of propagation
- 2) Electrical Structure as origin of energetic ions

3 Questions

- 1) Importance of the "spoke" phenomenon ?
- 2) Contribution of multiple charged ions?
- 3) Influence of Reactive Gases ?

Spokes are an electrical structure in HiPIMS plasmas

Gradients determine velocity and direction Internal electrical fields determine energy of the ions at the substrate

- At very high powers, homogeneous plasma is reached, High ion energies unaffected
- Multiple charged ions cause CX ions with higher energies
- Reactive HiPIMS hysteresis disappears for very high powers
- Reactive admixtures may cause and enhancement of the return effect

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